ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

METHOD FOR CONTROLLING LINEWIDTH IN ADVANCED LITHOGRAPHY MASKS USING ELECTROCHEMISTRY

Application Number:

Confirmation Number:

First Named Applicant:

Louis Kindt

Attorney Docket Number:

BUR920030115US1

Art Unit:

Examiner:

Search string:

(5780187 or 5707765 or 5935733 or 5935737 or 6139993 or 6235434 or 6309976

or 6368762 or 6368974 or 6627362 or 20020115000).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

ini	it	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	Z	1	5780187	1998-07-14	Pierrat et al.			
П		2	5707765	1998-01-13	Chen			
	\prod	3	5935733	1999-08-10	Scott et al.	-,		
		4	5935737	1999-08-10	Yan			-
		5	6139993	2000-10-31	Lee et al.			
		6	6235434	2001-05-22	Sweeney et al.			·
		7	6309976	2001-10-30	Lin et al.		/	
		8	6368762	2002-04-09	Ling			
		9	6368974	2002-04-09	Tsai et al.			
	2	10	6627362	2003-09-30	Stivers et al.			

US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init Cite.No	Pub. No.	Date	Applicant	Kind	Class	Subclass
201	20020115000	2002-08-22	Gupta et al.			

Signature

Examiner Name

8-11-05

Date